

INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)				Docket Number (Optional) END9200001-61	Application Number S-19457			
				Applicant(s) David J. Alcoe et al.				
*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
<i>JM</i>		5,316,803	5/31/94	White, Jr. et al.	427/554		12/10/92	
		5,536,579	7/16/96	Davis et al.	428/421		6/02/94	
		5,560,840	10/01/96	Covert et al.	216/108		12/19/94	
		5,626,771	5/06/97	Davis et al.	216/13		6/06/95	
		5,672,548	9/30/97	Culnane et al.	437/209		6/26/96	
		5,723,062	3/03/98	Covert et al.	252/79.2		5/28/96	
		5,726,863	3/10/98	Nakayama et al.	361/794		1/25/96	
		5,798,563	8/25/98	Feilchenfeld et al.	257/668		8/25/98	
		5,847,935	12/08/98	Thaler et al.	361/761		12/16/96	
		5,877,550	3/02/99	Suzuki	257/700		7/16/97	
		5,886,406	3/23/99	Bhansali	257/698		10/07/97	
FOREIGN PATENT DOCUMENTS								
	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)								
<i>JM</i>		MULTILAYER SUBSTRATE WITH LOW COEFFICIENT OF THERMAL EXPANSION, Nakamura et al., 2000 International Symposium on Microelect, pages 235-240.						
EXAMINER	<i>Jean M. Alcoe</i>			DATE CONSIDERED		5/6/02		
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.								

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				Filing Date		Group Art Unit		
<b>U.S. PATENT DOCUMENTS</b>								
*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
JW/M		5,926,377	7/20/99	Nakao et al.	361/763		11/17/97	
		5,989,443	11/23/99	Covert et al.	216/13		10/03/99	
		6,006,428	12/28/99	Feilchenfeld et al	29/852		4/01/98	
		6,054,758	4/25/00	Lamson	257/691		12/16/97	
		6,090,633	7/18/00	Yu et al.	438/15		9/22/99	
<b>FOREIGN PATENT DOCUMENTS</b>								
REF	DOCUMENT NUMBER	DATE	COUNTRY		CLASS	SUBCLASS	Translation	
							YES	NO
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EXAMINER <i>[Signature]</i>				DATE CONSIDERED <i>5/6/02</i>				
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